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DATE MAILED: 12/30/2003

APPLICATION NO.	FILI	NG DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/618,874	07/14/2003		Mukul Saran	TI-30597.1	5871
23494	7590	12/30/2003		EXAMINER	
TEXAS INSTRUMENTS INCORPORATED				ha, nathan w	
P O BOX 655474, M/S 3999 DALLAS, TX 75265				ART UNIT	PAPER NUMBER
,				2814	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
Office Action Summan	10/618,874	SARAN, MUKUL					
Office Action Summary	Examiner	Art Unit	_				
7	Nathan W. Ha	2814					
The MAILING DATE of this communication app Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  Status	36(a). In no event, however, may a re within the statutory minimum of thirty rill apply and will expire SIX (6) MON cause the application to become AR	ply be timely filed  (30) days will be considered timely.  HS from the mailing date of this communication.					
1) Responsive to communication(s) filed on 14 Ju	ly 2003.						
_	<u> </u>						
<ol> <li>Since this application is in condition for allowant closed in accordance with the practice under E.</li> </ol>	ce except for formal matte	rs, prosecution as to the merits is					
Disposition of Claims	,	,					
4)  Claim(s) 1-14 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5)  Claim(s) is/are allowed. 6)  Claim(s) 1-14 is/are rejected. 7)  Claim(s) is/are objected to. 8)  Claim(s) are subject to restriction and/or							
Application Papers	·						
9) The specification is objected to by the Examiner 10) The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to the d Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Examiner	pted or b) objected to b rawing(s) be held in abeyand on is required if the drawing(s	e. See 37 CFR 1.85(a). ) is objected to. See 37 CFR 1.121(d).					
Priority under 35 U.S.C. §§ 119 and 120		- 101 of 101111 1 0 102.					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau  * See the attached detailed Office action for a list of the priority application from the International Bureau  * See the attached detailed Office action for a list of the since a specific reference was included in the first since a specific reference was included in the first since and the since	have been received. have been received in Ap by documents have been re (PCT Rule 17.2(a)). If the certified copies not re priority under 35 U.S.C. Is sentence of the specificat isional application has been priority under 35 U.S.C. Is	polication No eceived in this National Stage eceived. 119(e) (to a provisional application) ion or in an Application Data Sheet. en received.					
Attachment(s)							
1) ⊠ Notice of References Cited (PTO-892) 2) □ Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) ☑ Information Disclosure Statement(s) (PTO-1449) Paper No(s) <u>7/03</u>	5) Notice of Info	nmary (PTO-413) Paper No(s) rmal Patent Application (PTO-152)					

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U.S. Patent and Trademark Office PTOI -326 (Rev 11-03) Application/Control Number: 10/618,874

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#### **DETAILED ACTION**

### Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-13 are rejected under 35 U.S.C. 102(b) as being anticipated by Cheng et al. (US 5,891,805, hereinafter, Cheng.)

In regard to claim 9, in fig. 21A, Cheng discloses a method of forming an IC capacitor, comprising:

providing a silicon substrate 201 with a first dielectric film 203 containing at least one copper layer 205, see also, col. 7, first paragraph;

forming a second dielectric layer 250 over the first dielectric layer and the copper layer;

forming a first conductive layer over the first dielectric layer, see fig. 21A; and

removing portion of the first conductive layer such that a portion of the second dielectric layer remains between the first conductive layer and the copper layer.

In regard to claim 10, Cheng further discloses forming copper contacts 235 to the first conductive layer, see col. 7, first paragraph; and

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forming a second copper layer that electrically contacts the copper contacts.

In regard to claim 11, the first conductive layer suggested to be aluminum, see col. 10, lines 34-36.

In regard to claim 12, see fig. 21A, where the dielectric layer is formed using a least two dielectric films, including 210, for example.

In regard to claim 13, layer 210 is a barrier layer, see col. 7, lines 32-36.

## Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 14 is rejected under 35 U.S.C. 103(a) as being unpatentable over Cheng as applied to claims 1-13 above, and further in view of Okada, US 6,448,652B1.

In regard to claim 14, Cheng discloses all of the claimed limitations as mention above. Cheng further suggests that the barrier/etch-stop can be formed by Titanium nitride or any other refractory materials. It should be noted that silicon nitride is a refractory material that is mentioned in Cheng. It is a well known material and widely used to form barrier/etch-stop since it had higher dielectric constant, above 6.

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Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to use silicon nitride in order to take advantage of well known material and prove the device characteristics since the higher constant provides netter barrier feature.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nathan W. Ha whose telephone number is (703) 305-3507. The examiner can normally be reached on M-TH 8:00-7:00(EST).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (703) 308-4918. The fax phone number for the organization where this application or proceeding is assigned is (703) 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Nathan Ha December 26, 2003

PRIMARY EXAMINER